

ABSTRACT OF THE DISCLOSURE

A liquid crystal display (LCD) device includes a first substrate and a second substrate, an organic light emitting element formed by interposing a first insulating layer on an outer surface of the first substrate, a second insulating layer and a protective layer formed in order over an entire surface of the organic light emitting element, a thin film transistor formed on the first substrate, a passivation layer formed over an entire surface of the first substrate including the thin film transistor, a pixel electrode formed on the passivation layer to be connected to the thin film transistor, a common electrode formed on the second substrate, and a liquid crystal layer formed between the first substrate and the second substrate. A method for fabricating the LCD includes the steps of forming a first insulating layer on an outer surface of a first substrate, forming an organic light emitting element on the first insulating layer, forming a second insulating layer over an entire surface of the organic light emitting element, forming a protective layer on the second insulating layer, forming a thin film transistor on the first substrate, forming a passivation layer over an entire surface of the first substrate including the thin film transistor, forming a pixel electrode on the passivation layer, and forming a liquid crystal layer between the first substrate and a second substrate.